

EV318285859

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Priority Application Serial No. .... 10/128,933  
Priority Filing Date ..... April 23, 2002  
Inventor ..... Werner Juengling  
Assignee ..... Micron Technology, Inc.  
Priority Group Art Unit ..... 2822  
Priority Examiner ..... J.L. Brophy  
Attorney's Docket No. .... MI22-2391  
Title: Semiconductor Processing Methods Of Forming A Contact Opening To A  
Conductive Line and Methods of Forming Substrate Active Area  
Source/Drain Regions

**PRELIMINARY AMENDMENT**

To: Mail Stop Patent Application  
Commissioner for Patents  
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Sir:

This is a preliminary amendment accompanying a Request for Continuation Application for the above-entitled patent application. Prior to examining the application, please enter the following amendments.

**AMENDMENTS**

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.